

## Master Syllabus

### PAR 1203 - Advanced Litigation

**Division:** Business and Public Services

**Department:** Paralegal

**Credit Hour Total:** 3.0                      **Lecture Hrs:** 3.0

**Prerequisite(s):** PAR 1103

**Other Prerequisite(s):** AND Restricted to Majors

**Date Revised:** January 2013

---

### Course Description:

The paralegal's role in the litigation process, from pleadings through discovery and trial. This course develops student paralegal skills in drafting pleadings, use of discovery tools and litigation software.

### General Education Outcomes:

- ▣ Oral Communication Competency
- ▣ Critical Thinking/Problem Solving Competency

### Course Outcomes:

#### Litigation Technology

Prepare an oral and written presentation for a case study using litigation software.

**Assessment Method:** Locally developed exams

**Performance Criteria:** Students must attain a minimum of 79% on exams.

**Assessment Method:** Simulations

**Performance Criteria:** Students must timely complete all assignments, meeting stated written and oral requirements at a performance rate of 79% or higher.

#### Electronic Discovery

Analyze and apply the Federal and Ohio Rules of Civil Procedure that apply to electronic discovery.

**Assessment Method:** Locally developed exams

**Performance Criteria:** Students must attain a minimum of 79% on exams.

**Assessment Method:** Simulations

**Performance Criteria:** Students must timely complete all assignments, meeting stated written and oral requirements at a performance rate of 79% or higher.

#### Traditional Discovery

Prepare discovery documents.

**Assessment Method:** Locally developed exams

**Performance Criteria:** Students must attain a minimum of 79% on exams.

**Assessment Method:** Simulations

**Performance Criteria:** Students must timely complete all assignments, meeting stated written and oral requirements at a performance rate of 79% or higher.

### Outline:

Pleadings  
Traditional Discovery  
Electronic Discovery  
Factual Research  
Litigation Technology